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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Thomas A. Figura, Kevin Donohoe, & Thomas Dunbar

Serial No.: 09/470,650

Filed: December 22, 1999

## Title: USE OF A PLASMA SOURCE TO FORM A LAYER DURING THE FORMATION OF A SEMICONDUCTOR DEVICE

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**RESPONSE TO THE OFFICE ACTION DATED MARCH 15, 2002**

**Commissioner for Patents  
Washington, D.C. 20231**

Dear Sir:

**Certificate of Mailing**

Applicants herein respond to the Office Action dated March 15, 2002.

## REMARKS

Claims 1-8, 10-14, 19, 23-24, 29-32, and 36-43 are pending.

Claims 1-8, 10-14, 19, 23-24, 29-32, and 36-43 are rejected.

Applicants request reconsideration of claims 1-8, 10-14, 19, 23-24, 29-32, and 36-

43

## I. Rejection of claims under §112

The Examiner rejected claims 1-8, 10-14, 19, 23-24, 29-32, and 36-43 under §111 ¶1, arguing that Applicants should demonstrate the Specification's disclosure of a reasonable number of species representing "today's broad genus encompassing the